

IFW

<h1 style="text-align: center;">TRANSMITTAL FORM</h1> <p style="text-align: center;">(to be used on all correspondence after initial filing)</p>		ATTORNEY DOCKET NO.	
		70020.0076USWO	
		U.S. APPLICATION SERIAL NO.	CONFIRMATION NO.
		10/576,075	6664
		FILING DATE	
		April 14, 2006	
INVENTOR(S)	EXAMINER	GROUP ART UNIT	
Isao NISHIMURA et al.	Unassigned	Unassigned	
TITLE OF APPLICATION			
SILANE COMPOUND, POLYSILOXANE, AND RADIATION-SENSITIVE RESIN COMPOSITION			

ADDRESS TO:	Mailstop Amendment Commissioner for Patents P.O. BOX 1450 ALEXANDRIA, VA 22313-1450
-------------	--

ENCLOSURES

- ☒ Transmittal Form
- ☒ Information Disclosure Statement
- ☒ PTO Form 1449 (1 Sheet)
- ☒ Copies of Cited Documents (10)
- ☒ Return Postcard

☒ Please charge Deposit Account No. 13-2725 in the amount of \$0.00 to cover any required fees. In the event any variance exists between this amount and the Patent Office charges for filing the above-noted documents, including any fees required under 35 CFR 1.136 for any necessary extension of time to make the filing of the attached documents timely, please charge or credit the difference to Deposit Account No. 13-2725. Further, if these papers are not considered timely filed, then a request is hereby made under 37 CFR 1.136 for the necessary extension of time.

CORRESPONDENCE ADDRESS

☒ The address associated with Customer Number: **23552** OR ☐ the correspondence address below.

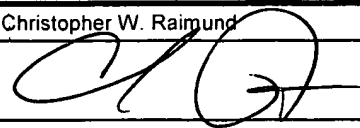
Name

Address

City

State

Zip Code

NAME	Christopher W. Raimund	REGISTRATION NO.		47,258
SIGNATURE		DATE	December 18, 2006	TELEPHONE
				202 326-0300
NAME		REGISTRATION NO.		



INFORMATION DISCLOSURE STATEMENT 37 C.F.R. § 1.97(b)		ATTORNEY DOCKET NO. 70020.0076USWO	
		U.S. APPLICATION SERIAL NO. 10/576,075	CONFIRMATION NO. 6664
		FILING DATE April 14, 2006	
INVENTOR(S) Isao NISHIMURA et al.	EXAMINER Unassigned	GROUP ART UNIT Unassigned	
TITLE OF APPLICATION SILANE COMPOUND, POLYSILOXANE, AND RADIATION-SENSITIVE RESIN COMPOSITION			

Mailstop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

With regard to the above-identified application, the items of information listed on the enclosed Form 1449 are brought to the attention of the Examiner.

This statement should be considered because it is submitted before the mailing date of a first Office Action on-the-merits. Accordingly, no fee is due for consideration of the items listed on the enclosed Form 1449.

In accordance with 37 C.F.R. §1.98(a)(2), a copy of each document or other information listed on the enclosed Form 1449 is provided.

No representation is made that a reference is "prior art" within the meaning of 35 U.S.C. §§ 102 and 103 and Applicants reserve the right, pursuant to 37 C.F.R. § 1.131 or otherwise, to establish that the reference(s) are not "prior art." Moreover, Applicants do not represent that a reference has been thoroughly reviewed or that any relevance of any portion of a reference is intended.

Consideration of the items listed is respectfully requested. Pursuant to the provisions of M.P.E.P. 609, it is requested that the Examiner return a copy of the attached Form 1449, marked as being considered and initialed by the Examiner, to the undersigned with the next official communication.

Please charge any additional fees or credit any overpayment to Deposit Account
No. 13-2725.

December 18, 2006

Date

P.O. Box 2903
Minneapolis, Minnesota 55402-0903
Telephone No. (202) 326-0300
Facsimile No. (202) 326-0778

23552

Patent & Trademark Office

Respectfully submitted,

MERCHANT & GOULD, P.C.



Christopher W. Raimund
Registration No. 47,258



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE
STATEMENT (PTO 1449)

ATTORNEY DOCKET NO.

70020.0076USWO

U.S. APPLICATION SERIAL NO.

10/576,075

CONFIRMATION NO

6664

FILING DATE

April 14, 2006

INVENTOR(S)

Isao NISHIMURA et al.

EXAMINER

Unassigned

GROUP ART UNIT

Unassigned

TITLE OF APPLICATION

SILANE COMPOUND, POLYSILOXANE, AND RADIATION-SENSITIVE RESIN
COMPOSITION

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	B	0 159 428 (Equivalent of JP6-12452)	04-13-1984	EP			X	
	C	5-188598	07-30-1993	JP			X	
	D	5-323611	12-07-1993	JP			X	
	E	6-12452	02-16-1994	JP				X
	F	8-160623	06-21-1996	JP			X	
	G	11-60733	03-05-1999	JP			X	
	H	2002-220471	08-09-2002	JP			X	
	I	2002-268225	09-18-2002	JP			X	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	J	Kunz, R. R. et al., "Outlook for 157-nm Resist Design," Journal of Photopolymer Science and Technology, vol. 12(4), pp. 561-569, 1999.					
	K	Kunz, R. R. et al., "Advances in Resist Technology and Processing XVI," Proceedings of SPIE, vol. 3678, pp. 13-23, 1999.					

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if the reference is considered, whether or not the citation is in conformance with MPEP 609. Draw a line through the citation if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.